

First principles calculations on structure, bonding, and vibrational frequencies of SiP₂

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Pyrite type SiP₂ is reinvestigated by first principles calculations on various levels of functionals including local density approximation, generalized gradient approximation, Becke-Lee-Yang-Parr hybrid functional, and the Hartree-Fock method. SiP₂ is seen as a model compound with molecular [P–P] entities and [SiP₆] octahedra. Structure and bonding are addressed by electronic structure calculations. Special attention is spent on P–P and Si–P bonds in terms of bond lengths and respective stretching modes from simulated Raman spectra. The electronic structure is analyzed in both direct and momentum space by the electron localization function and site projected density of states. The main goals of this work are to understand the nature of chemical bonding in SiP₂ and to compare and contrast the different methods of calculation. © 2011 American Institute of Physics. [doi:10.1063/1.3633951]

INTRODUCTION

There is a big variety of different phosphorus compounds and even new modifications of the element are still being discovered.^{1,2} Continuing interest in chemistry and bonding of phosphorus particularly exists for the solid state. Most phosphorus structures tend to be connected by single bonds both in its modifications like in P₄ or recently found phosphorus nanorods.³ Charged partial structures of P are well known for various phosphide compounds such as Cu₂P₂₀ (Ref. 4) or Cu₂I₂P₁₄,^{5,6} the first binary polyphosphide with entirely preserved channels of phosphorus chains. The orthorhombic modification of SiP₂ forms related Si–P-channels. It was discovered by Wadsten⁷ in 1967 by temperature gradient solid state synthesis.

Here, we focus on the cubic modification of SiP₂ that is probably the simplest polyphosphide with P₂ dumbbells in a pyrite type structure. It serves as a prototype for novel iso-electronic dipnictides like SiN₂ that was predicted as an ultrahard large gap semiconductor.⁸ SiP₂ was first synthesized by Tanaka⁹ from high temperature and high pressure solid state synthesis, later by halogen transport from the elements under autogenous pressure.¹⁰ The key question to understand is the chemical bonding of SiP₂ which seems to be straightforward in the first place but presents some surprises. The pyrite type structure with 6-fold coordination of Si favors a Zintl like description.¹¹ Electron transfer from less electronegative Si atoms to more electronegative P atoms results in Si⁴⁺ and [P₂]⁴⁻ ions (isoelectronic to [S₂]²⁻ in FeS₂). However, light elements such as Si and P are expected to form at least partially covalent bonds as concluded by von Schnering from x-ray diffraction data.¹²

Looking at compounds that are isostructural to pyrite-type SiP₂, such as NiP₂, PtP₂, or pyrite itself (FeS₂), it is remarkable that these compounds are semiconductors. Nevertheless, SiP₂ was characterized as a semimetal with a nearly filled Brillouin zone.¹⁰ The possibility of a semiconducting status was ruled out due to a rising electrical resistivity with increasing temperature. Furthermore, galvanomagnetic and optical measurements predicted the presence of both holes and electrons. From the analysis of Fermi surfaces, Farberovich¹³ proposed metallic type conductivity for SiP₂. When it comes to electronic structure calculations, just little attention has been paid to SiP₂ to date. Indeed, early band structure calculations from 1974 and 1976 (Refs. 14 and 15) characterized SiP₂ as semimetal. However, the true nature of chemical bonding in SiP₂ and the reason for the metallic behavior is still unclear.

The bonding situation was reconsidered by our group lately¹⁶ in terms of calculations of IR/Raman frequencies with modern *ab initio* methods that allow for an enhanced treatment of exchange and correlation effects. As it can be seen by a more extensive approach in this work, these effects turn out to be crucial for the bond description in SiP₂. It was carried out systematically due to calculated bond lengths, electronic structures in direct (electron localization function, ELF) and reciprocal space, and vibrational frequencies. From subsequently presented results, one can gain a deeper insight into the bonding situation in SiP₂. Furthermore, different basis sets and methods of calculation were evaluated in terms of correctness and accuracy.

METHODS

Calculations have been performed with the CRYSTAL98 (Ref. 17) and the CRYSTAL06 codes.¹⁸ With the aid of these codes, the electronic structure was computed

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according to a linear combination of Gaussian type functions scheme. Full geometry optimizations, simulation of vibrational spectra, and electronic band structure calculations were done within the local density approximation (LDA),¹⁹ the Perdew-Burke-Ernzerhof generalized gradient approximation (GGA-PBE),²⁰ and the Becke-Lee-Yang-Parr hybrid functional (B3LYP) (Ref. 21) of the Kohn-Sham density functional theory (DFT).²² By comparison, periodic Hartree-Fock (HF) (Ref. 23) calculations were performed as this method uses exact exchange but neglects correlation. The ELF and data related to the theory of atoms in molecules and crystals (AIM) (Ref. 24) were computed from CRYSTAL98 density with TOPOND98.²⁵

Pack-Monkhorst and *Gilat* nets were calculated with shrinking factors of (6 12) (119 k-points). The convergence criterion with respect to the total energy was set to 10^{-8} a.u. Anderson's method²⁶ of mixing the Fock and Kohn-Sham matrix was used. All electron basis sets were applied with reoptimized outer shells.^{16,27} To examine the impact of the basis sets on the calculated geometrical parameters, calculations of P–P and Si–P distances were exemplarily performed with different basis sets (Fig. 2). For P, 88–311G* was used. For Si, BS1 (88–31G*) includes less diffuse shells whereas there are additional shells implemented in BS2 (88–311G*) leading to a more diffuse character. For BS3 (88–1111G*), the basis set for each method was optimized separately. From spin polarized calculations, no magnetic ground state was detected.

Results I: Crystal structure optimisations

From a local point of view, the bond analysis refers to P–P dumbbell units and SiP₆ octahedra as the 2 important building blocks of pyrite (FeS₂) type SiP₂ (space group *Pa* $\bar{3}$). Si atoms form an *fcc* partial structure (crystallographic position 4a) like Na in NaCl. Instead of single-atom anions, phosphorus dumbbells are located in the Si₆ octahedral vacancies. This results in 4 formula units (FU) SiP₂ per unit cell. With the P atoms on sites 8c (x, x, x) (see also Ref. 28), a coordination of P atoms by 3 Si and 1 P neighbor is realized that reminds of carbon in an ethane molecule (Fig. 1, left). From the point of view of Si atoms, a 3D network of Si[P₂]₆ polyhedra is formed

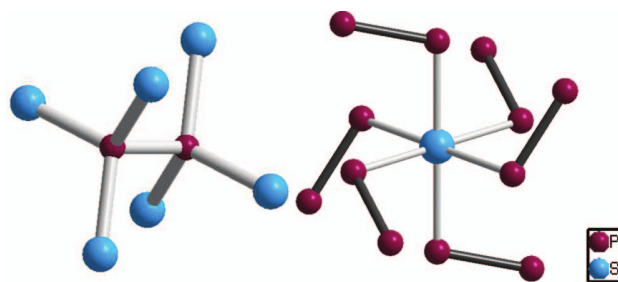


FIG. 1. Structural fragments in SiP₂. (Left) Coordination sphere of a phosphorus dumbbell. (Right) Extended coordination sphere of a Si atom (the lines between the atoms are no bonds but serve as guide for the eye).

(Fig. 1, right). Contrary to edge-linked octahedra in the rock salt structure, the phosphorus dimers in SiP₂ cause a deviation of P–Si–P angles from 90° to 94° and corner-linking of the resulting trigonal antiprism. Questions on chemical bonding refer to the covalence of the Si–P bonds and whether the P₂ dumbbell can be seen as [P₂]^{4−} with the 3 lone pairs pointing towards Si⁴⁺ ions.

As a first approach to evaluate the bond types in SiP₂, atomic distances are analyzed (Table I, Fig. 2). Calculated bond lengths P–P and Si–P are in good agreement with experimental data on all applied levels of theory and basis sets. The overall deviation of the geometrical parameters ranges between −0.91% (for the LDA calculated Si–P distance) and 1.71% (for the B3LYP calculated lattice constant). The maximum deviation between results obtained with different basis sets is about one percent. Consequently, the effect of the basis set is supposed to be relatively small with respect to the accuracy of the calculations. All following results are presented on the basis of BS2 only as BS2 calculations did not cause any problems with the convergence of energy with either method. As a reference, highly accurate experimental data from neutron and x-ray diffraction at 60 K (Ref. 29) are used. Thus, the P–P length in SiP₂ of 2.17 Å is in the range of short P–P bonds known for white P₄ (Ref. 30) or Cu phosphides^{4,5} but shorter than in black P (2.22 Å),³¹ or in recently discovered fibrous P (>2.23 Å).¹ The Si–P bonds (2.39 Å), on the other hand, are significantly longer than the sum of the covalent radii (2.28 Å) of P (1.11 Å) and Si (1.17 Å).

TABLE I. Calculated crystal structure data.

SiP ₂	a/Å	X(P)	d(Si–P)/Å	d(P–P)/Å	V/Å ³	d(Si–P)/d(P–P)	<P–Si–P/°	<Si–P–P/°	ΔE _{gap} /eV
Expt. (298 K) ²⁹	5.707	0.391	2.397	2.162	185.88	1.109	93.9	...	
Expt. (60 K) ²⁹	5.681	0.391	2.386	2.157	183.35	1.106	103.6	...	
HF	5.739	0.392	2.413	2.156	189.01	1.119	93.9	...	4.8
LDA	5.656	0.390	2.375	2.155	180.96	1.102	104.0	...	
PBE/GGA	5.737	0.391	2.410	2.174	188.82	1.109	93.8	...	
B3LYP	5.778	0.391	2.430	2.173	192.95	1.118	103.6	...	
							93.9	...	
							103.6	...	

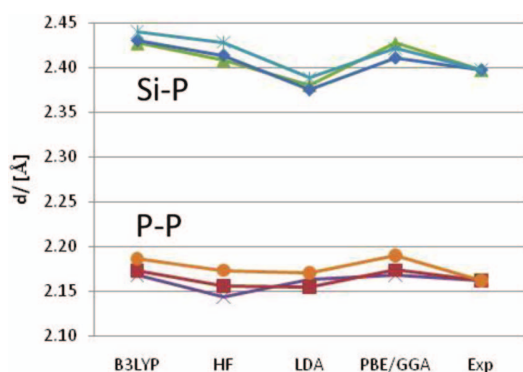


FIG. 2. The Si–P (upper) and P–P (lower) distances are displayed against different methods of calculation (B3LYP, HF, LDA, PBE/GGA) and the experimental value. Different curves were calculated with different basis sets.

A closer look at the calculated data exhibits some trends that help to distinguish bonding contributions estimated by the various levels of theory. The first trend concerns the well-known underestimation of bond lengths by LDA within the DFT.³² An overestimation of bond lengths is found when non-local GGA effects are considered. Switching off correlation effects with the HF method also increases the bond lengths. Finally, the predicted bond lengths in SiP₂ by B3LYP calculations show a larger deviation from the experiment than LDA, GGA, or even HF. This is rather unexpected, keeping in mind results on molecules and even silicates.³³ It can be concluded that both non-local effects from GGA and exact exchange from HF result in overestimation of bond lengths. B3LYP sums up both effects that are more expressed for Si–P than for P–P.

As a next step, the bonding situation in SiP₂ is analyzed by means of vibrational frequencies (related to bond strength). The pyrite type structure offers a simple identification of stretching modes related to the P–P and Si–P bonds. Calculated vibrational frequencies of selected Raman modes of SiP₂ are compared to experimental data in Table II. Respective deviations from the experimental value are visualized in Fig. 3 (only results from the largest basis set are shown). As no experimental IR data is available for SiP₂ (IR modes for metallic compounds are highly incapable of measurement), just a comparison with Raman modes is possible at this point. By the correlation of vibrational P–P stretching modes and bond lengths, further clarification of the nature of bonding in the P–P dumbbells should be achieved. The experimental values for the in-phase and out-of-phase P–P stretching modes of 461 and 485 cm⁻¹ (Ref. 28) are in the range of typical values for P–P single bonds. The according stretching mode for

TABLE II. Calculated vibrational frequencies for selected Raman modes.

	A_g	E_g	T_g^1	T_g^2	T_g^3
Expt. ²⁸	461	353	319	337	485
LDA	470	364	331	347	494
GGA/PBE	459	357	322	339	484
B3LYP	480	373	329	355	510
HF	555	423	387	410	593

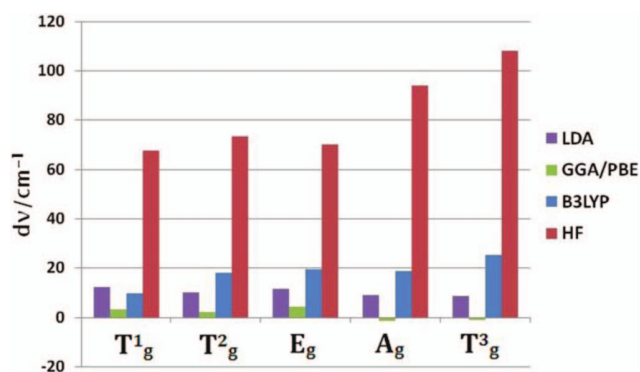


FIG. 3. Deviations of differently calculated Raman modes of SiP₂ (LDA, GGA/PBE, B3LYP, and HF) from the experimental value (x-axis).

P–P bonds in black phosphorus, for instance, is 470 cm⁻¹. In contrast, the stretching mode of P₂ from Raman studies in Ar matrices³⁴ is 774 cm⁻¹. Hence, only a slight tendency to higher bond order can be concluded for SiP₂.

A general overestimation of the vibrational frequencies can be seen for all levels of theory. Once again, the results from the GGA/PBE method match best with the experimental data. Predicted data from LDA calculations also results in good agreement with the experiment whereas B3LYP performs worse. Hartree-Fock calculations overestimate the frequencies by an order of magnitude compared to LDA. Neglecting correlation for the bond strength and elasticity obviously results in a large error that cannot be seen from bond distances only.

In consideration of these results, the importance of correlation and non-local effects in SiP₂ becomes evident. Exact exchange as included in HF or B3LYP does not lead to a better description as it can be observed for molecules or silicates.³³ The calculated and the experimentally found bond lengths both indicate single bonds within the P₂ units. This conclusion supports both ionic P₂⁴⁻ entities and an entirely covalent network.

The effects of HF and DFT levels of theory should be understood from the electronic structure of SiP₂. It is illustrated in “Results II: Electronic structure” section from direct (ELF, AIM) and reciprocal space analyses.

Results II: Electronic structure

The bonding situation of SiP₂ in direct space is shown from the ELF in Fig. 4 for a slide through a phosphorus dumbbell and neighboring Si atoms. ELF values from 0 to 1 are represented by a color scale from black to red. For all calculations, ELF maxima between two P atoms of the dumbbell and between P and Si atoms indicate covalent bonding. In case of the P–P unit, the ELF maximum is located exactly in the middle of the P–P connecting line due to homopolar bonding. Heteropolar bonding with a partially ionic character is anticipated for Si–P. This is underlined by the deviation of the ELF maximum from a connecting line of a Si and a P atom. From the point of view of the P–P entity, the ELF maximum tends towards an angle (106°) that is closer to the tetrahedral angle (109°) than the direct line to the next Si atom (104°). A similar

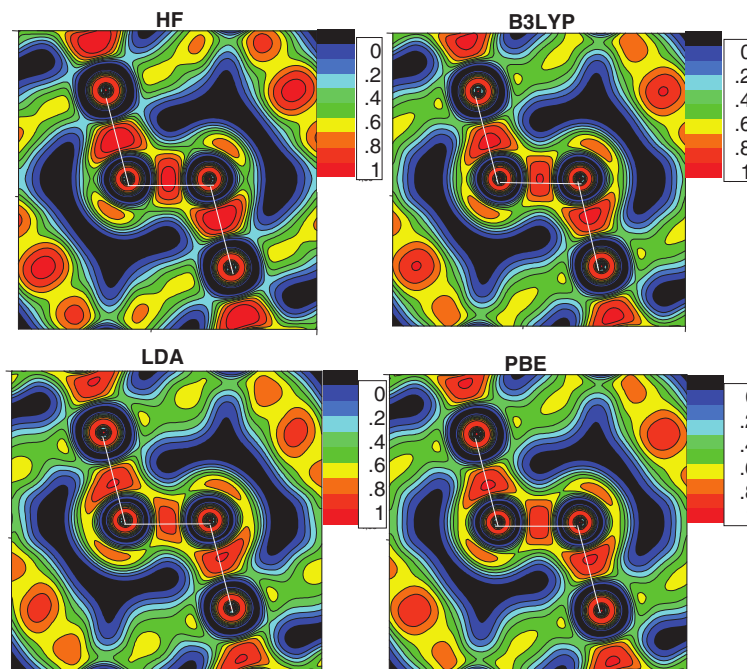


FIG. 4. Electron localization function for SiP_2 displayed for a plane containing a P_2 dumbbell and two Si atoms (values from 0 to 1 are represented by a color scale from black to red). Calculations based on the HF method are shown as well as calculations based on the DFT functionals B3LYP, LDA, and PBE.

observation was pointed out by von Schnering³⁵ from deformation densities based on x-ray and neutron diffraction measurements. He concluded on an ionic character of the bond. This is confirmed by the ELF results that show at least a polarized and bent bond.

Somehow surprisingly, the computed ELF gives very similar results on all levels of theory. The only effect is higher localization for both bonds from HF calculations compared to the results from LDA, GGA, and B3LYP. Thus, the results from the AIM analysis of the charge density according to Bader^{24,36} have to be treated carefully. *Beta sphere* radii, atomic charges, and volumes of Si calculated by *zero-flux surface* integrations as presented in Table III indicate a high charge of +2.5 for Si according to the HF calculation. In face of a formal valence of +4, this can be interpreted by assuming a partially covalent character of the Si–P bond. The calculations with the hybrid functional B3LYP as well as LDA and GGA predict lower charges and thus less polarized bonds. The atomic volumes and beta sphere radii follow the same trend. As a hybrid of the mentioned methods, the outcome of the B3LYP functional ranges in between, albeit it is closer to the values obtained by the DFT calculations. Apparently, neglecting electron correlation in favor of an exact exchange energy

(HF) leads to a more polarized Si–P bond description. However, the differences in the AIM results are simply related to small shifts of the zero flux surface within the Si–P bonding region. Combining ELF and AIM results, one must point out localized bonds for SiP_2 from all levels of theory. They are more related to typical covalent bonds found for B–C–N-systems³⁷ than to ionic bonding found in NaCl where no ELF bonding maxima are found.

Concerning its crystal structure, Raman data, and ELF analysis, SiP_2 appears to demonstrate covalent bonding properties (cf. many isostructural pyrite type pnictides that have been classified as semiconductors). Nevertheless, several studies have proven that SiP_2 is a compensated conductor.^{15,38} With galvanomagnetic and reflectance measurements, Donohue categorized SiP_2 as semimetal with a nearly filled Brillouin zone. A small value of the Hall constant was determined due to the presence of both holes and electrons. Furthermore, conductivity measurements illustrated rising electrical resistivity with increasing temperature. Supplementary, Donohue³⁹ performed measurements of the de Haas – van Alphen effect and came up with an energy-level diagram for SiP_2 . He proposed a completely filled valence band but no bandgap and thus no energy barrier for electrons to transfer to the antibonding band. To come to an analogous conclusion with theoretical investigations, our band structure calculations illustrate how highly the results depend on the calculation method.

So why is SiP_2 not a simple semiconductor like FeS_2 or even silicates and what was the effect of correlation found from vibrational frequencies? The answer is given by the electronic band structure calculations within HF, B3LYP, PBE/GGA, and LDA levels of theory (Fig. 5). Whereas the constitution and the sequence of the band structures are very

TABLE III. Atomic charges, beta sphere radii, and atomic volumes of Si calculated by *zero-flux surface* integrations according to Bader's AIM.

	$Q(\text{Si})/e$	$V(\text{Si})/\text{\AA}^3$	$r_\beta(\text{Si})/\text{\AA}$
HF	2.47	41.76	0.81
B3LYP	1.50	67.04	0.93
PBE	1.39	67.96	0.94
LDA	1.39	65.09	0.91

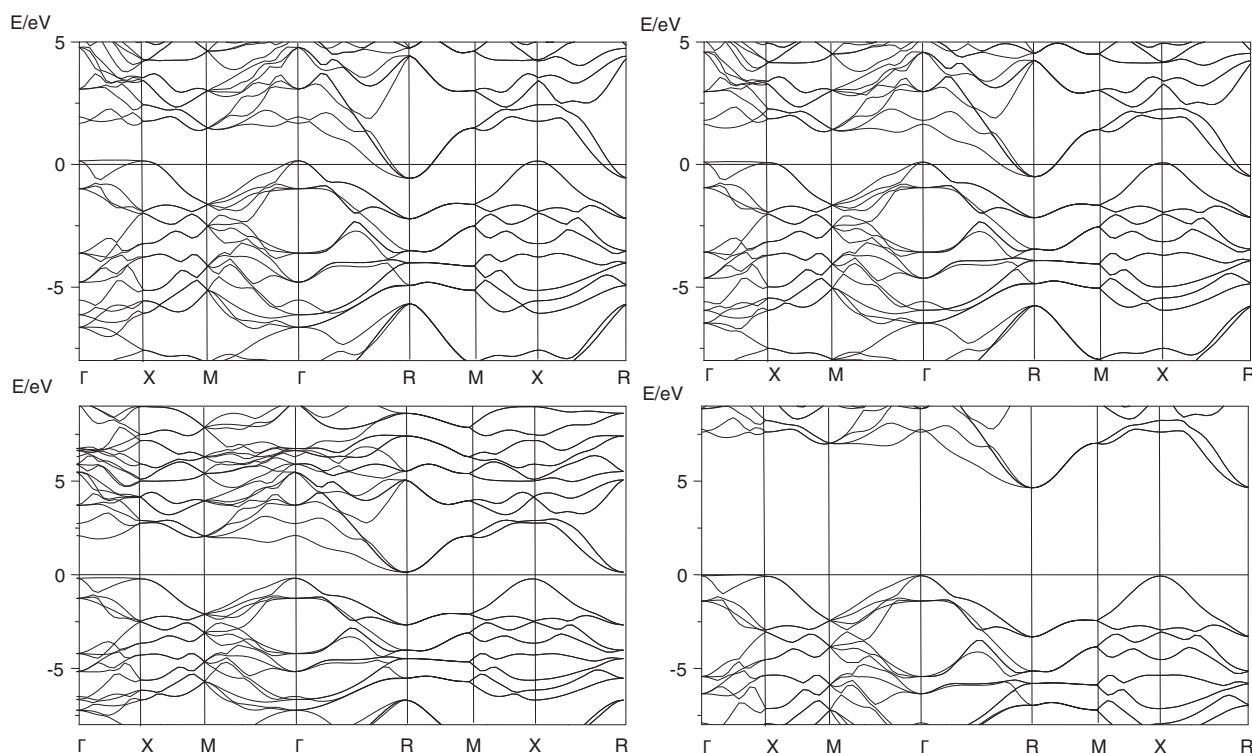


FIG. 5. The band structure of SiP₂ – calculated with LDA (top left), GGA (top right), B3LYP (bottom left), and HF (bottom right).

similar, differences are found in the distance between the valence band and the conduction band. LDA and PBE/GGA predict an indirect overlap of VB and CB due to a semi metal, B3LYP calculations result in a vanishing and HF in a large bandgap. The gap overestimation by HF is well known but for SiP₂ it is crucial as it results in different electronic characteristics. Systems with large gaps between occupied and unoccupied states like molecules or covalent systems like silicates are thus sufficiently described by HF. SiP₂, on the other hand, is found on the edge between covalent and delocalized metallic bonding.

Keeping this in mind, the good agreement of LDA and GGA predictions with experimental data is due to the fact that they consider both covalent and metallic characteristics. In line with the results in Ref. 40, the properties of SiP₂ are dominated by its semimetallic properties. But why is SiP₂ a semimetal with an indirect overlap of valence and conduction bands? Why does it not form a gap like FeS₂ or as predicted from HF? As an answer, the present calculations show a flat band segment between the Γ and the X point that has not been reported previously. It indicates instability due to antibonding or nonbonding states. Related band segments at the Fermi level were also related to the appearance of superconductivity.⁴¹ It seems that the occupation of this valence band region is avoided in SiP₂ and it is energetically better to occupy the minimum of the conduction band at the R point.

An analysis of the band characteristics was carried out with the aid of projected DOS calculations (PDOS) based on LDA (Fig. 6). The 3s, 3p, and 3d orbitals of silicon and phosphorus are displayed in addition to the total DOS. In accor-

dance with OPW DOS calculations and experimental x-ray emission bands of Farberovich,⁴⁰ the total DOS generates five maxima below the Fermi level.

The lowest three maxima for silicon result from 3s, the one at about -4 eV from 3p, and the one close to the Fermi energy from 3d contributions. These 3d contributions are required to explain the distorted octahedral coordination of silicon atoms in SiP₂ as an sp^3d^2 hybridization for Si has to be assumed in this case. An sp^3d^2 hybridization for Si was already predicted by Donohue in 1969 (Ref. 39) to explain the unusual 6-fold coordination of Si.

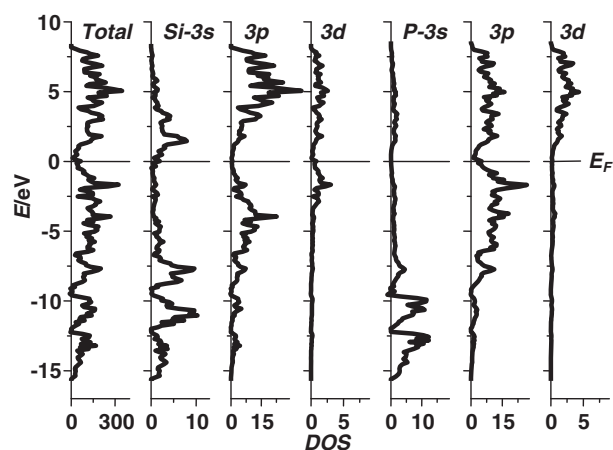


FIG. 6. Density of states (DOS) and projected density of states (PDOS) of Si and P in SiP₂.

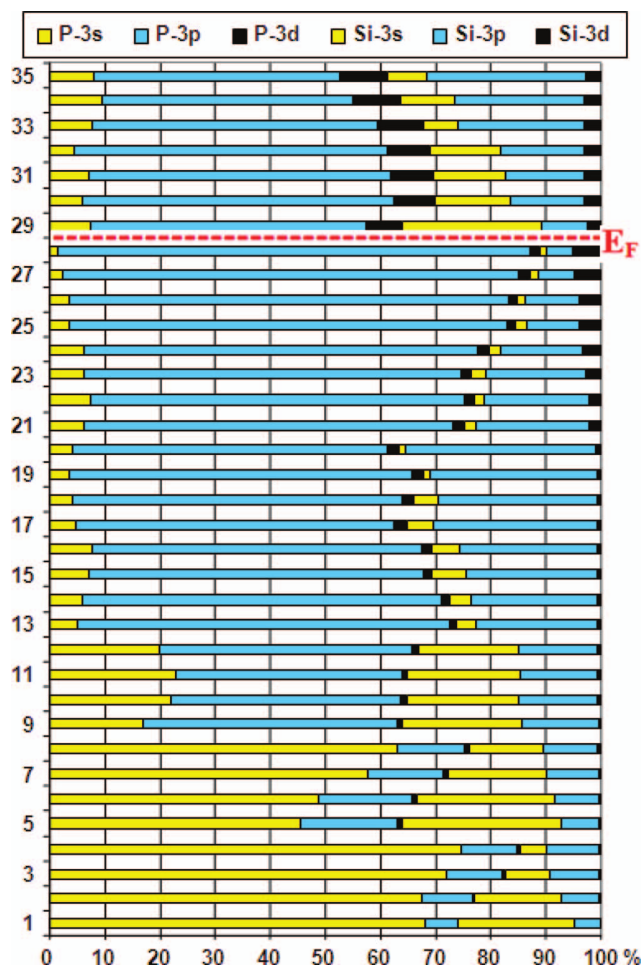


FIG. 7. Projection of the P and Si s , p , and d fractions of the respective bands in SiP_2 obtained from a numerical integration of the projected density of states of the individual bands.

The two strong maxima between -15 and -10 eV of the phosphorus $3s$ states confer to σ P–P and σ Si–P bonds. P- $3p$ states are also located below the Fermi level and participate in σ and π bonds to neighboring atoms. The $3d$ states of the phosphorus PDOS plot are above the Fermi level so they do not participate in any binding states. This is coherent with the predicted distorted tetrahedral coordination of P atoms in SiP_2 and it indicates an sp^3 hybridization of P atoms.

To gain deeper insight into band contributions of the atomic orbitals, a detailed breakdown according to the PDOS of the individual bands is presented in Fig. 7. The present approach separates distinct bands along the E scale. Thus, band overlap is not disturbing like in the PDOS picture. Bands one to 35 (of 56) are taken into consideration; they are subdivided into six sections which point out the respective percentages of the $3s$, $3p$, and $3d$ orbitals of phosphorus and silicon. The edges of the VB and the CB are given between bands 28 and 29. This picture refers to the semiconducting limit predicted from B3LYP where 28 bands are occupied by 56 valence electrons per formula unit (Si: 4VE, P: 5VE, 4FU). In agreement with the PDOS (Fig. 6), mostly s character is indicated in the first block of eight bands due to σ and σ^* bonds of the P–P dumbbells. The overlaying bands predominantly demon-

strate p character according to significant p contributions in the bonds of sp^3 and sp^2d^3 hybridized P and Si atoms. Below the Fermi level, there is only little overall d character; especially phosphorus barely donates any binding d contributions. Nevertheless, an increasing Si d character below the Fermi level is a sign of the distorted octahedral coordination of silicon atoms, which requires sp^2d^3 hybridization. Passing the Fermi level, an abrupt rise of the Si s character refers to distinctive antibonding states. One must conclude that the metallic characteristics are due to the occupation of bands that are related to Si- $3s$ and P- $3p$ states. This is preferred over the occupation of nearly pure P- $3p$ states in the flat valence band region. A reason might be P–P-interaction as estimated by von Schnering,^{29,35} cf. the conduction band minimum that could be caused by bonding of Si- $3s$.

CONCLUSION

The present work is dedicated to a detailed investigation of the ambivalent bonding situation in pyrite type SiP_2 . First principles calculations were performed on various levels of theory including DFT-LDA/GGA, HF, and hybrid B3LYP to understand the different bonding contributions. From all calculations, bond distances were predicted in very good agreement with experimental data. The same is found for Raman frequencies with the exception of HF. Coordination, bond distances, and vibrational frequencies are in line with covalent or ionic models according to a Zintl description $\text{Si}[\text{P}_2]$. Real space analysis by the ELF indicates typical covalent P–P and polarized P–Si bonds. The reason for the different bond descriptions by the different methods of calculation becomes apparent when the band structures are taken into consideration. HF and B3LYP predict SiP_2 to be a semiconductor analogously to FeS_2 . Only LDA and GGA predict a semimetal-like indirect overlap of the valence and the conduction band in agreement with experimental data. This behavior can be explained by a flat band region in the valence band of SiP_2 . It is caused by antibonding P- $3p$ states on top of the VB while the conduction band minimum is lowered by Si- $3s$ -P- $3p$ interactions. Further investigations concerning SiP_2 could focus on the flat band segment between Γ and X. If it can be lowered to the Fermi level, interesting properties like super-conductivity or spin-polarization could be observed.

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